P roperties of atom ic intercalated carbon K₄ crystals

M asahiro $\operatorname{Itoh}_{1}^{1,2}$ Seiichi Takam i_{1}^{1} Yoshiyuki K awazoe, and Tadafum i Adschiri^{1,2}

¹Institute of Multidisciplinary Research for Advanced Materials,

Tohoku University, Aoba-ku, Sendai 980-8577, Japan

²Advanced Institute for Materials Research, WPI,

Tohoku University, Aoba-ku, Sendai 980-8577, Japan

³Institute for M aterials Research, Tohoku University, Aoba-ku, Sendai 980-8577, Japan

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The stability of atom ic intercalated carbon K₄ crystals, XC₂ (X = H, Li, Be, B, C, N, O, F, Na, Mg, Al, Si, P, S, Cl, K, Ca, Ga, Ge, As, Se, Br, Rb or Sr) is evaluated by geometry optimization and frozen phonon analysis based on rst principles calculations. A lthough C K₄ is unstable, NaC₂ and MgC₂ are found to be stable. It is shown that NaC₂ and MgC₂ are metallic and semi conducting, respectively.

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I. IN TRODUCTION

Recently, m athem atical analysis elucidated that 120 bonding form s a 3-D 10-m ember ring periodic structure (K₄ structure) and can be regarded as the tw in of the diam ond structure¹. From the view point of carbon chem – istry, 120 bonding is of the sp² bond type, which form a 2-D structure with a 6-m ember ring, and the K₄ carbon structure has not been experimentally discovered. Because of the wide applications of carbon materials (graphite, am orphous, diam ond, CNT and fullerene²), if such a new member exists in nature or can be synthesized, then this new material should have a very signi – cant im pact.

The stability and properties of this carbon K₄ structure have been studied using rst principles calculations^{3,4}. It is interesting to note that carbon K₄ is metallic^{3,4}, although the phonon calculation results indicate the structure is unstable⁵. Compared with the graphite structure of sp² bonding, the binding energy per bond is slightly lower. This is possibly one of the reasons for the instability of the carbon K₄ crystals against the them al vibration.

It is well understood that atom ic intercalation to the carbonaceous materials changes the structural stability and som etim es provides totally di erent properties. We propose that atom ic intercalation will a ect the electronic distribution in the K₄ crystals and possibly stabilize the structure. O ver 40 years ago, disilicides such as SrSi₂ were found to have K₄ type ame of Sf. This result encouraged us to investigate in purity intercalated carbon K₄ system s although such crystal structures are not found in the carbide system⁷.

This study exam ines the structural stability and several properties of the atom ic intercalated carbon K₄ crystals, XC_2 (X = H, Li, Be, B, C, N, O, F, Na, Mg, Al, Si, P, S, Cl, K, Ca, Ga, Ge, As, Se, Br, Rb or Sr) by rst principles calculations.

II. COMPUTATIONALMETHODS

First principles calculations based on density functional theory^{8,9} are performed for the K₄ type crystals XC_2 , C, Si and $SrSi_2$ using the V ienna Ab-initio Sim ulation Package (VASP)¹⁰.

Local density approximation $(LDA)^{11,12}$ is used for the exchange-correlation energy functional. In the present calculations, all these crystals are considered as spin-un-polarized system s.

To reduce the computational costs, the projectoraugmented wave method¹³ is used to approximate electrons in each atom in the crystal. For H, Li, Be, B, C, N, O, F, Na, Mg, Al, Si, P, S, Cl, K, Ca, Ga, Ge, As, Se, Br, Rb and Sr, valence electrons of $1s^1$, $2s^1$, $2s^2$, $2s^22p^1$, $2s^22p^2$, $2s^22p^3$, $2s^22p^4$, $2s^22p^5$, $3s^1$, $3s^2$, $3s^23p^1$, $3s^23p^2$, $3s^23p^3$, $3s^23p^4$, $3s^23p^5$, $3s^23p^64s^1$, $3s^23p^64s^2$, $4s^24p^1$, $4s^24p^2$, $4s^24p^3$, $4s^24p^4$, $4s^24p^5$, $4s^24p^65s^1$ and $4s^24p^65s^2$ are considered, respectively.

To evaluate the stability of the $XC_2 K_4$ crystal structure, the following procedure is adopted.

(1) The original conventional unit cell for the carbon K₄ crystal is shown in Figure 1(a). Four X atoms (X = H, Li, Be, B, C, N, O, F, Na, Mg, Al, Si, P, S, Cl, K, Ca, Ga, Ge, As, Se, Br, Rb, or Sr) are allocated to reduced coordinates $(\frac{1}{8}, \frac{1}{8}, \frac{1}{8}), (\frac{7}{8}, \frac{5}{8}, \frac{3}{8}), (\frac{3}{8}, \frac{7}{8}, \frac{5}{8}), (\frac{5}{8}, \frac{3}{8}, \frac{7}{8})$ in the original unit cell. The primitive unit cell of XC_2 with P 4₃32 (O⁶) symmetry is shown in Fig. 1(b). The symmetric plane of the atom ic intercalated system is shown in Fig. 1(c). As shown in Fig. 1(d), three adjacent atoms (red) are aligned on a straight line with the same distance (C-X, and X-C).

(2) Binding energy versus volume curve is evaluated and tted using Mumaghan's equation of state¹⁴. For these calculations, Brillouin zone integration is performed for 8 8 8 k-point meshes generated by the Monkhorst-Pack scheme. The residual minimization/direct inversion in the iterative subspace method is used to accelerate the convergence of self-consistent total energy calculations. The convergence criterion is set to be within 1 10 8 eV /form ula unit cell. The cut-o energy for the plane-wave expansion of valence electrons for the primitive unit cell is determined, so that the number of plane waves is constant over a full range of the lattice constant. A round the minimum of binding energy versus volume curve, the cut-o energies were set to be 500 and 400 eV for C and XC₂, and Si and XSi₂ crystals, respectively.

(3) The unit cells obtained from step (2) are optimized with freedom of the atom ic con guration under the sym - metry constraint.

(4) The unit cells obtained from step (3) are optim ized without any constraint on the crystal structure. The convergence criterion is set to be within 1 $\,10^{-7}$ eV/A unit cell.

(5) The frozen phonon calculations were perform ed using the FROPHO $code^{15}$ which is based on Parlinski-Li-K awazoe method¹⁶. To obtain the force constants for the phonon calculations, the atom ic displacements are set to be 0.01 A. The Born - von K arm an boundary condition is applied for each primitive unit cell obtained with multiplication after steps (3) and (4) for the phonon calculation. In these calculations, the primitive cells are multiplied by 2 for each direction of the unit vector.

III. RESULTSAND DISCUSSIONS

The structure with K $_4$ crystal am e considered for C, XC₂, Si and SrSi₂ systems in the present study m aintain K $_4$ type crystal am e composed of C or Siw ith distortion through the whole process of the geom etry optim ization. Furtherm ore, the crystal sym m etry is m aintained within an accuracy of less than 0.001A. The lattice constant (a), volume at lattice constant (V₀), cohesive energy per atom (E coh) and bulk m odulus at V₀ (B₀) are evaluated for the fully optim ized structure. In this study, E coh for XC₂: E coh; X C₂ is de ned as

$$E_{coh;XC_2} \qquad \xrightarrow{E_{XC_2} + N_{X atom} - E_{X atom} + N_{C atom} - K_4} E_{C atom};$$

Here, E_A and N_A are the total energy and the number of atom s for A, respectively. To obtain these values, M urnaghan's equation of state is used to the binding energy versus volume curve. P arameters in the equation are determined using the least squares method in the range of about $0.8V_0 < V < 1.2V_0$, where the root mean square is set to be less than 5.0 meV/atom.

The obtained values of a, V_0 , $E_{\rm coh}$, and B_0 for the crystals are shown in Figure 2(a). In XC₂, the values of a and V_0 generally increase with the atom ic number of X. G enerally, the values of a for the XC₂ crystals are larger than that for carbon K₄. That is, generally the carbon K₄ am es are expanded by intercalating X to the carbon system s.

However, the values of V_0 for X = H, Li, ..., S, are smaller than that of carbon K_4 while those for X = C l, ..., Sr are larger. This is because of the su ciently wide

vacant spaces in carbon K $_4$ that is compensated by X atom s and the increase of the occupied spaces by X atom s for the increase of the atom ic number of X .

On the other hand, the values of $E_{\rm coh}$ decrease with the increasing period of X. There is a strong negative correlation with a and V₀ as shown in the correlation coe cients: $r_{a~E~coh}$ = -0.792 and $r_{V_0~E~coh}$ = -0.796. For each period of X in the XC₂, E_{coh} generally shows largest values for interm ediate elements X: IIIB or IVB. This enhanced energy gain can be explained by the com pletion of the electronic shell in C atom s composing K $_4$ type ame, the bonds form ation with X in the XC₂ crystals and the bonds expantion which weaken the bonds. The E coh values of the XC_2 are not larger than that of the carbon K4. This is apparently resulted from the relative weakness of the X-C bonds in the XC₂ crystals com pared with the C-C bonds in the carbon K₄ crystal. Subsequently, the absence of correlation between $E_{\rm coh}$ and dynam ical stability is shown.

The values of B₀ also decrease with the increasing period of X, similar to the case of E_{coh}. The B₀s of XC₂ are generally smaller than that of C. There is a strong correlation between B₀ and E_{coh} as indicated by the correlation coe cient: $r_{E_{coh}}$ B₀ = 0.848.

From the values of a and V_0 in Siand SrSiz, the relation shown in the C and XC_2 systems also seems to hold for the Siand XSiz systems. However, the values of E _coh and B_0 of SrSiz are larger than those of Si. This relation is apparently di erent from the cases of C and XC_2 systems. This can be attributed to the X-Sibond strength being much higher than that of the Si-Sibonds in XSiz.

To understand the correlation between the stability and the structure in detail, the nearest-neighbour distances between di erent atom s speci ed in Fig. 1 (e) d C-C, dX-C_A, dX-C_B, dX-C_C, dX-C (the average of all dX-C) and dX-X as well as the angle $\setminus X - C_A - C_B$, and the m inim al dihedral angle for the nearest-neighbour C atom s \setminus C-C-C-C are investigated.

As shown in Fig. 2(b), in general d C-C, \overline{d} X-C and d X-X increase with the increasing atom ic number in X, similar to the cases of a and V₀. The d C-C and \overline{d} X-C show very strong correlation with the a, indicated by the correlation coe cients: $r_{a \ d_{x} \ c} = 0.930$ and $r_{a \ \overline{d_{x}} \ c} = 0.987$. These distances have also correlation with E coh: $r_{E_{coh} \ d_{c} \ c} = -0.630$ and $r_{E_{coh} \ \overline{d_{x}} \ c} = -0.741$, although the values are sm aller.

It is apparent that the correlations shown in \overline{d} X-C with a and E_{coh} are resulted from the very strong correlation of d X-C_A and d X-C_B with a and E_{coh} as indicated by the correlation coe cients: $r_{a \ d_{X} \ c_{A}} = 0.824$, $r_{a \ d_{X} \ c_{B}} = 0.973$, $r_{a \ d_{X} \ c_{C}} = 0.180$, $r_{E_{coh} \ d_{X} \ c_{A}} = -0.759$, $r_{E_{coh} \ d_{X} \ c_{B}} = -0.796$, and $r_{E_{coh} \ d_{X} \ c_{C}} = -0.051$.

Here, it should be noted that the each inequivalent atom ic distance between X and C: $dX - C_A$, $dX - C_B$, and d X- C_C show interesting X dependence. The XC₂ system s with X of 3rd, 4(5)th periods show distinct di erences between X = IA and IIA, and other X s. In the compound

with X = IA or IIA, the dX-C_A and dX-C_B are relatively larger while dX-C_C is smaller compared with those of the other compounds with X of the neighbour atom ic number. The angle $\setminus X$ -C_A-C_B show distinct smaller values for the compounds with X = IA and IIA and this is attributed to the X dependence of the dX-C_A and d X-C_B. The dihedral angle \setminus C-C-C-C shown in Tab. II also show smaller values for the compounds with X = IA or IIA although the di erences with other compounds are very small. Apparently, those di erences are due to the number of the outer most valence electrons in X. However, an exceptional trend is shown in the system s with X of 2nd period for those values and the trend can be attributed to the elemental closeness between the X and C.

The relative position of X in the crystal is maintained resulting in $r_{a d_X = x} = 1.000$. Therefore, d X -X can be considered as a standard distance in the XC₂ system s. To emphasize the similarity of the structures, various distance ratios of the nearest-neighbour distances to d X -X are shown in Fig. 2 (c). A lthough signi cant larger (sm aller) d C -C / d X -X, d X -C / d X -X, and d C -C_C / d X -X (d C -C_A / d X -X) are shown in the crystals with X = C, N, and O, these ratios are alm ost constant in the same group of X.

In Figure 3, the phonon density of states (DOS) without step (4) for C and XC_2 (X = H, Li, Be, B, C, N, O, F, Na, Mg, Al, Si, P, S, Cl, K, Ca, Ga, Ge, As, Se, Br, Rb or Sr), Siand SrSi₂ with K₄ type ame of C or Siare depicted. From the above discussions and Fig. 2 (a), the intermediate value of a realized for the compounds with X in 3rd (4th) (4.5-4.8 A) and the accompanied interatom ic distances in these crystals seem to make the band narrower. Namely, the inter atom ic distances roughly determ ine the vibrational frequency range in these crystals. The imaginary frequency modes rarely appear in NaC₂, MgC₂ and SrSi₂ although they appear in relatively wide imaginary frequency range in C and Si.

For the structures of C, NaC₂, MgC₂, Si and SrSi₂ obtained after step (4), the phonon DOS and dispersion relationship are also evaluated. As shown in Fig. 4, the phonon DOS for the fully optimized structures of the other XC_2 crystals show alm ost the same shapes as those of the optimized structures from step (3). Therefore, it is expected that the discussion in the previous paragraph is signi cant and skipping step (4) is expected to be effective for reducing the com putational cost in this study.

A s shown in F igure 4, in carbon K $_4$, although the in aginary frequency mode is not appear at the point, it appear in wide range of other k points as indicated by Y ao et al⁵. On the other hand, silicon K $_4$ has in aginary modes even at the point. N am ely, the carbon and silicon K $_4$ crystal structures are on a high rank of saddle points in those potential energy surfaces and the lifes of them are expected to be very short in nature.

O n the other hand, in our calculations although N aC $_2$, M gC $_2$ and SrSi $_2$ have im aginary frequencies in the acoustic m odes slightly around the point, there are no im ag-

inary modes in the other k points. These suggest that those structures are stable although they break the structures against the phonon vibration with long wave length lim it. The existence of the $SrSi_2$ K₄ in nature⁶ suggests that the results in this study based on the density functional theory can predict the therm all stability of the structure. From this fact and the calculation results, the stable existence of K₄ type crystal structures in NaC₂ and MgC₂ is expected in nature although they do not realize maximum E_{coh} in the considered XC₂ crystals.

From the maximum frequencies obtained for diam ond (1300 cm ¹ for C¹⁸, 500 cm ¹ for Si¹⁹) and graphite (1600 cm ¹ for C)¹⁸, the orders of both C-C and Si-Si chem ical bonds can be considered less than 1, as discussed by Yao et al⁵. Therefore, based on the rough expectation from the mono atom ic system s, the orders are expected to be less than 1 between the atom s com – posing K₄ type am e of NaC₂, MgC₂ and SrSi₂ crystals. The characters of chem ical bonds are analysed from the valence charge distribution as described below .

To understand the stability of the K₄ system s, the valence charge distributions are analysed. Fig. 5 show svarious types of distribution in the conventional or the prim – it ive unit cells for the fully optimized C, NaC₂, MgC₂, Si and SrSi₂ crystals with K₄ type ame. Fig. 5(a) details planes selected to show the distribution of quantities noted in Figs. 5(c), (e), and (g). The populations around the Sr atom s are neglected for easier com parison in Figs. 5(c) and (e).

Figures 5 (b) and (c) show the isosurface and contour of charge density. Apparently, the valence charge is locally distributed along the lines between adjacent C or Si atom s of the K₄ type am e for the considered system s. It should be noted that a distinctive di erence appears between the charge distribution of the C (X C₂) and Si(SrSi₂) crystals in the intermediate region between the nearest-neighbour atom s in those am es. The charge is m ore localized to the C than Siatom s. These features are also indicated in the diam ond crystal structures as show n in the previous studies²⁰. It can be said that the atom ic intercalation change the distribution slightly. However, as discussed for the properties of the crystals.

Figures 5 (d) and (e) shows the di erences between the valence charge density of the crystals (ex. $_{N \ aC_2}$ (r)) and their separated components: the intercalated atom s (ex. $_{N \ a}$ (r)) and the ame (ex. $_{C_2}$ (r)). As shown in Fig. 5 (d), the signi cant excess charge is shown in the region between the adjacent Na-C, Mg-C and Sr-Si for NaC₂, MgC₂ and SrSi₂, respectively; therefore suggesting bond creation in those regions. Furtherm ore, as shown in Fig. 5 (e), in NaC₂, MgC₂ and SrSi₂, the charge accum ulations increase in the region of type orbitals while those decrease along the type bonds; suggesting that the type bonds are strengthened and the type bonds are weakened. On the other hand, the maximum frequency of the phonon modes shown in Fig. 4 is less than the mono atom ic system s. Therefore, the net bond orders in

the K $_4$ type am e are expected to be decreased by the atom ic intercalation.

Here, the nature of the bonds is noted from the information of the ELF. Figs. 5(f) and (g) show the isosurface (0.8 [-]) and the contour. As shown here, C, NaC₂, MgC₂, Siand SrSip has similar ELF distribution between the adjacent C-C and SiSi. However, the feature of type bonds formation is strengthened with signi cance. The relatively smaller value of $\ C - C - C - C \ (SiSiSiSi)$ seems to have correlation with this feature. The strengthened type bonds seem to stabilize the structures against the them alvibration. From the comparison with the case of graphite, the absense of the type bonds indicated by Yao et al.⁵, is not con rm ed in our calculations.

The stabilization of atom ic intercalated carbon crystals is realized from delicate balance of bonding. A s shown in the valence charge density, the form ation of strongly polarized type bonds between Na or Mg and C_A and the strength enhanced bonds seem s to stabilize the structure of NaC₂ and MgC₂. The discrim inative stability seem s to be realized by the properous atom ic radii of X and the completion or near completion of the electronic shell of the each C atom in the K₄ type ame by X = IA or IIA . Sim ilar mechanism of the stability is expected to exist in the Si and X Si₂ system s.

Figure 6 show sX-ray di raction (XRD) patterns of the fully optim ized crystal structure of C, NaC₂, MgC₂, Si and SrSi₂. M onochrom atic radiation with wave length 1.541 A is assumed in these calculations. As shown in this gure, the compounds have speci c XRD peaks at larger 2 compared with the pure K₄ crystals.

Figure 7 shows the electron band structures, DOS, and local DOS of valence electrons for the atom s com posing K₄ type ame and the intercalated atom s in the fully optim ized C , N aC $_2$ and M gC $_2$ and the Si and SrSi $_2$ crystals, respectively. From the bottom energy levels to the upper levels, the angular momentum for the electronic states successively changes in the order of s, p and d character, although every component appears in most states. From the bottom energy levels to those around the Ferm i level, the band structures are similar in these crystals. N aC $_2$ and M gC₂ K₄ show a metallic and semiconducting feature, respectively, while carbon K $_4$ is metallic. A s show n in Fig. 6, both Si and SrSi2 have m etallic features. It is notew orthy that the previous st principles calculations for SrSi2¹⁷ also show qualitatively the same result with the present calculation.

IV. CONCLUSIONS AND SUMMARY

The stability of the atom ic intercalated carbon K₄ crystals, XC_2 (X = H, Li, Be, B, C, N, O, F, Na, Mg, Al, Si, P, S, Cl, K, Ca, Ga, Ge, As, Se, Br, Rb, and Sr), are evaluated from the geometry optimization and the frozen phonon analysis based on the stability relations. NaC₂ and MgC₂ are found to be stable although C K₄ is not stable. The form ation of strongly

polarized type bonds between Na or Mg and C_A and the strength enhanced bonds seems to stabilize the structure of NaC₂ and MgC₂. The discriminative stability seems to be realized by the properous atom ic radii of X and the completion or near completion of the electronic shell of the each C atom in the K₄ type ame by X = IA or IIA. The NaC₂ and MgC₂ are found to be metallic and sem i conducting, respectively.

V. APPENDIX

The values presented in Figure 2 are listed in Table I and Π .

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FIG.1: (a) The conventional unit cell of the carbon K₄ crystal with I4₁32 (O⁸) sym m etry. (b) Initial structure of the primitive unit cell of XC₂ crystal with K₄ ame of C with P4₃32 (O⁶) sym m etry. (c) 2 2 2 super cell of the (b). The sym m etric plane of the impurity intercalated system. (d) Three adjacent atoms (C-X-C) that aligne in a straight line with equivalent distance (C-X and X-C) are encircled with red thick line in (c). (e) An extracted structure. The C atoms can be classi ed into C_A, C_B and C_C.



FIG.2: (a) Determined lattice constant(a), volume at a (V_0), cohesive energy (E_{coh}), and bulk modulus at V_0 (B₀), and (b) the nearest-neighbour distances and angles for the fully optimized C, XC₂, Si and SrSi₂ crystal structures with K₄ type ame within LDA. The classi cation of the C (Si) atom s (C_A , C_B , and C_C)) is based on the irreducibility of the crystal symmetry as shown in Fig. 1. (c) The distance ratios.



FIG. 3: Phonon density of states (DOS) of XC₂ (X = H, Li, Be, B, C, N, O, F, Na, Mg, Al, Si, P, S, Cl, K, Ca, Ga, Ge, As, Se, Br, Rb and Sr), C, Siand SrSi₂ crystalwith K₄ type ame of C, or Si. The structures are obtained from geometry optimization under symmetry constraint to the initial structures.



FIG.4: (Left) Phonon density of states (DOS) of partially and fully optim ized structures of C, NaC₂, MgC₂, Siand SrSi₂ with K₄ type ame of C or Si. (Right) The phonon dispersion relationship for the fully optim ized structures.



FIG.5: (a) The conventional or the primitive unit cells for the fully optimized C, NaC₂, MgC₂, Si and SrSi₂ crystals with K₄ type of am e of C or Si. The planes are selected to show the distribution of the valence charge density, dimensioned between the valence charge density of the crystals (ex. $_{NaC_2}$ (r)) and their separated components: the intercalated atoms (ex. $_{Na}$ (r)) and the am e (ex. $_{C_2}$ (r)), and the electronic localization function (ELF). The isosurfaces of the valence charge density (1.5, 1.0, 1.0, 0.35 and 0.35 e/A³ for C, NaC₂, MgC₂, Si and SrSi₂, respectively) (b) and the contours (c). The isosurfaces of the valence charge density (0.05, 0.05 and 0.025 + (-)e/A³ coloured with red (blue) for NaC₂, MgC₂ and SrSi₂, respectively) (d) and the contours (e). The isosurfaces of the ELF (0.8 [-]) (f) and the contours (g). For (c) and (e), the high population around the Sr atom s is neglected for easier comparison. X C rySD en²¹ was used for the visualization.



FIG.6: XRD patterns for the fully optimized structures of C, NaC2, MgC2, Siand SrSi2 with K4 type ame of C or Si.



FIG.7: Electronic density of states (DOS) and the dispersion relationship for the fully optimized conventional or primitive unit cells of C, NaC₂, MgC₂, Si and SrSi₂ crystals with K₄ type ame of C or Si.

Com ponent	a [A]	V_0 [A 3 /atom]	$\rm E_{coh}$ [eV /atom]	$B_0 [10^{11} \frac{N}{m^2}]$	
C 4	4.082	8.502	7.702	2.67	
HC ₂	4.025	5.433	6.335	3.00	
LiC ₂	4,250	6,396	6,231	2.41	
B eC 2	4.412	7.158	6.401	2,30	
BC ₂	4.328	6.758	7,259	2.94	
CC ₂	4.326	6.747	7,295	3.16	
NC ₂	4.348	6.850	7.003	3,33	
0 C 2	4,218	6,252	7.221	3.67	
FC ₂	4,296	6.607	6.273	2.98	
N aC 2	4.526	7.728	5.476	2.06	
M gC ₂	4.506	7.623	5.856	2,29	
ALC 2	4.598	8,102	6,214	2,29	
SiC ₂	4.622	8,227	6,301	2,39	
PC ₂	4.619	8,214	5.805	2.42	
SC 2	4.644	8,345	5,261	2,38	
C LC 2	4.699	8.646	5.152	2.18	
KC2	4.920	9,926	4.606	1,30	
C aC 2	4.803	9,232	6.099	1.82	
G aC 2	4.679	8.536	5.831	2.41	
G eC 2	4.731	8.823	5.875	2,19	
A sC 2	4.773	9.059	5.485	2,20	
SeC ₂	4.823	9.351	4.987	2,10	
B rC 2	4.908	9.852	4.668	1.86	
RbC ₂	5.175	11.550	4.172	0.95	
SIC 2	5.096	11.030	5.545	1.44	
Si	6.354	32.089	4,220	0.46	
SrSiz	6.436	22,216	4.634	0.66	

TABLE I: Determ ined lattice constant(a), volume at a (V_0), cohesive energy (E $_{coh}$), and bulk modulus at V_0 (B $_0$) for the fully optimized C, XC $_2$, Si and SrSi $_2$ crystal structures with K $_4$ type amewithin LDA.

TABLE II: Determ ined nearest-neighbour distances and angles for the fully optim ized C, XC_2 , Si and SrS_2 crystal structures with K₄ type amewithin LDA. The classication of the C (Si) atom s (C_A , C_B and C_C)) is based on the irreducibility of the crystal symmetry as shown in Fig. 1. The smallest dihedral angles for the nearest-neighbor C (Si) atom s of K₄ ame are also show n.

C om ponent	dC-C [A]	dX-C [A]	dX-C _A [A]	dX-C _B [A]	d X-C _c 🛛] d X – X [A]	\ X-C _A -C _B []	\ C-C-C-C []
C 4	1.443	2,209	1.768	2,282	2,282	2.500	90.000	70.529
HC ₂	1.492	2,226	1.350	2.180	2,563	2.463	100.081	67.946
LiC ₂	1.525	2,286	2.071	2.444	2.199	2.601	84.183	69.686
B eC 2	1.581	2.409	1.683	2.417	2.644	2.701	95.477	69.782
BC ₂	1.582	2.383	1.526	2.354	2.698	2.650	98.434	68.732
CC ₂	1.628	2.405	1.391	2.341	2.808	2.649	101.393	67.330
NC ₂	1.679	2.437	1.295	2.347	2.908	2.661	103.471	67,202
O C 2	1.582	2.343	1.365	2,282	2.729	2.582	101.180	65.807
FC ₂	1.524	2,333	1.741	2,372	2.492	2,628	92.955	70.313
N aC 2	1.614	2.436	2.152	2,585	2,381	2.769	85.408	70.005
M gC ₂	1.628	2.422	2.244	2.608	2,295	2.757	83.057	69.323
ALC 2	1.624	2.483	2.006	2.572	2.554	2.813	89.592	70.525
SiC ₂	1.637	2.508	1.890	2.555	2.666	2.827	92.542	70.369
PC ₂	1.634	2.503	1.916	2.559	2.643	2.825	91.904	70.439
SC ₂	1.645	2.520	1.920	2,573	2.666	2.843	92.100	70.420
C LC 2	1.663	2.548	1.938	2.601	2.698	2.874	92.170	70.412
KC ₂	1.752	2.649	2.322	2.804	2.602	3.011	85.787	70.088
C aC 2	1.730	2.584	2.369	2.773	2.466	2.940	83.574	69.498
G aC 2	1.653	2.530	2.020	2.613	2.617	2.863	90.101	70.529
G eC 2	1.673	2.556	2.082	2.653	2.617	2.896	89,211	70.513
A sC 2	1.685	2.578	2.071	2.667	2.659	2.919	89.841	70.528
SeC ₂	1.704	2.608	2.069	2.689	2.707	2.951	90.387	70.525
B rC 2	1.736	2.659	2.067	2.728	2.787	3.004	91,257	70.490
RbC ₂	1.845	2.786	2.453	2.954	2.729	3.167	85.575	70.042
SrC 2	1.834	2.740	2.507	2.939	2.619	3.118	83.684	69.533
C om ponent	dSi-Si[A]	dX-SiA]	dX-Si _A [A]	dX-Si _B [A]	dX-Si 🏾 🗛] d X - X [A] `	∖X-Si₄-Si₃ [] \ Sisisisi[]
Si	2,247	3.439	2.752	3.553	3.553	3.891	90.000	70,529
SrSiz	3.463	2,358	3.324	3.772	3,200	3.941	81,270	68.605